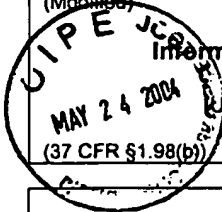


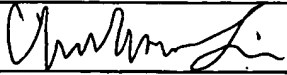
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| Substitute Form PTO-1449 (Modified) | U.S. Department of Commerce Patent and Trademark Office | Attorney's Docket No. 10559-894001 | Application No. 10/763,467 |
| Information Disclosure Statement by Applicant (Use several sheets if necessary) | | Applicant Hai Deng et al. | |
| | | Filing Date January 22, 2004 | Group Art Unit |



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| Examiner Initial | Desig. ID | Document Number | Publication Date | Patentee | Class | Subclass | Filing Date If Appropriate |
| | AA | | | | | | |
| | AB | | | | | | |
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| | | | | | | | Yes | No |
| | AH | | | | | | | |
| | AI | | | | | | | |
| | AJ | | | | | | | |

| Other Documents (include Author, Title, Date, and Place of Publication) | | |
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| Examiner Signature  | Date Considered 12/26/06 |
| EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant. | |